

Characterizing craniomaxillofacial anomalies in achondroplasia : from Jean Delaire to 3D morphometrics analysis

Anne Morice^{1,2}, Sophie Eche¹, Lucie Griffon³, Brigitte Fauroux³, Laurence Legeai-Mallet², Roman Hossein Khonsari^{1,2}, Geneviève Baujat⁴, Arnaud Picard¹, Natacha Kadlub¹



Institutions :

1. Service de Chirurgie Maxillo-Faciale et Chirurgie Plastique, Hôpital Universitaire Necker - Enfants Malades, Assistance Publique - Hôpitaux de Paris, Centre de Référence Maladies Rares MAFACE Fentes et Malformations Faciales, Université de Paris, Paris
2. Laboratoire 'Bases Moléculaires et Physiopathologiques des Ostéochondrodysplasies', INSERM UMR 1163, Institut Imagine, Paris
3. Unité 'Ventilation non invasive et sommeil de l'enfant', Hôpital Universitaire Necker - Enfants Malades, Assistance Publique - Hôpitaux de Paris
4. Service de Génétique Médicale, INSERM UMR 1163, Université Paris Descartes-Sorbonne Paris Cité, IMAGINE Institute, Necker Enfants Malades Hospital, Paris, France.

Achondroplasia is the most common cause of rhizomelic dwarfism, and is linked to FGFR3 activating mutations, leading to alterations in endochondral ossification processes, characterized by growth plate disorganization and premature fusion of skull base synchondrosis. The craniofacial phenotype is characterized by a large skull and prominent forehead, maxillary retrusion, and nasal root saddle, of variable severity. Heterogeneity of craniofacial phenotype and its causes in achondroplasia needs to be elucidated.

The aim of our study was to quantify craniomaxillofacial anomalies in a retrospective series of 15 achondroplasia patients. Cephalometric analyses were performed according to Delaire's method, as well as 3D morphometrics studies based on 3D CT-scans. Correlation studies were then performed between several skull base and maxillofacial parameters, to better understand the link between reduction of anteroposterior skull base length, midface retrusion, and the severity of the obstructive sleep apnoea syndrome.